

Integrated band strength for the three most intense mid-infrared bands of frozen N₂O deposited at 16 K on two different substrates (Si and KBr). The experimental procedure and band identification are given in Fulvio et al. (2009, *Spectrochimica Acta A*, 72, 1007-1013). Please refer to this article when use the values given below.

Substrate: Peak position (cm ⁻¹)	Si A (cm molecule ⁻¹)	KBr A (cm molecule ⁻¹)
2239	6.55×10^{-17}	5.69×10^{-17}
1295	1.22×10^{-17}	1.07×10^{-17}
2581	1.63×10^{-18}	1.5×10^{-18}

Note:

- Errors on band strengths are of the order of 10 %.